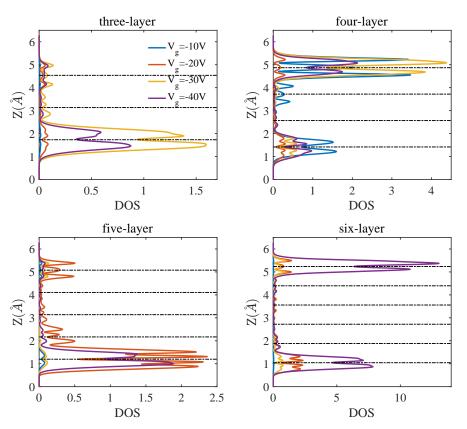
## Supplementary Information: Journal of Materials Chemistry C: A novel electrically controllable volatile memory device based on few-layer black phosphorus

Liwen Zhang,<sup>*a,b,e*</sup> Zhizhou Yu,<sup>*c*</sup> Lei Zhang,<sup>*a,b,e,\**</sup> Xiaohong Zheng,<sup>*d*,†</sup> Liantuan Xiao,<sup>*a,e*</sup> Suotang Jia,<sup>*a,e*</sup> Jian Wang<sup>*b*</sup>

In this supplementary material, we will show further transport properties details of our proposed model.

Figure 1 presents the LDOS at the Fermi level versus *Z* direction when different vertical gates are applied. It is clear that the LDOS mainly localizes in the topmost or bottom layers and becomes larger as the gate voltage increases.



**Figure 1** The LDOS at Fermi level when different vertical gate voltages are applied in electrode. The horizontal dashed-dot black lines represent the central atomic position of each layer.

<sup>c</sup> School of Physics and Technology, Nanjing Normal University, Nanjing 210023, China

<sup>&</sup>lt;sup>a</sup>State Key Laboratory of Quantum Optics and Quantum Optics Devices, Institute of Laser Spectroscopy, Shanxi University, Taiyuan 030006, China <sup>b</sup>Department of Physics and The Center of Theoretical and Computational Physics, The University of Hong Kong, Pokfulam Road, Hong Kong, China

<sup>&</sup>lt;sup>d</sup>Key Laboratory of Materials Physics, Institute of Solid State Physics, Chinese Academy of Sciences, Hefei 230031, China

<sup>&</sup>lt;sup>e</sup>Collaborative Innovation Center of Extreme Optics, Shanxi University, Taiyuan 030006, China

<sup>\*</sup>zhanglei@sxu.edu.cn

<sup>&</sup>lt;sup>†</sup>xhzheng@theory.issp.ac.cn